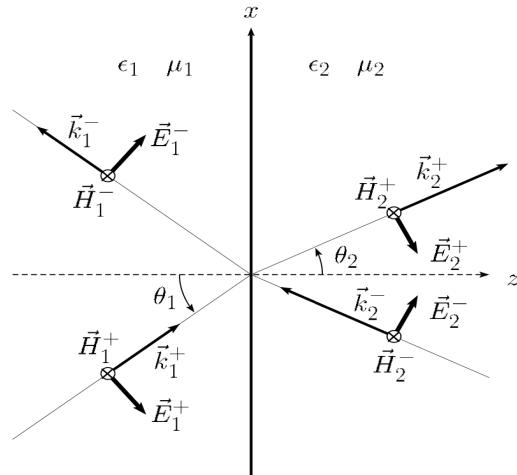


אופטיקה של חומרים דו-מימדיים

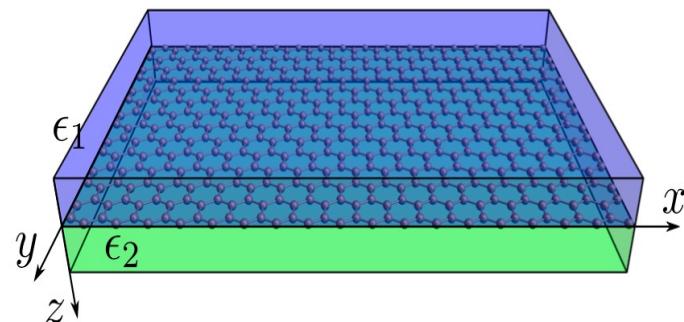
2D semiconductors – Transition Metal Dichalcogenides •

Polaritons, DR and the TMM



$$\tilde{\mathbf{M}}^{(p)} = \frac{1}{2} \begin{pmatrix} 1 + \frac{\epsilon_1}{\epsilon_2} \frac{k_{2z}}{k_{1z}} & 1 - \frac{\epsilon_1}{\epsilon_2} \frac{k_{2z}}{k_{1z}} \\ 1 - \frac{\epsilon_1}{\epsilon_2} \frac{k_{2z}}{k_{1z}} & 1 + \frac{\epsilon_1}{\epsilon_2} \frac{k_{2z}}{k_{1z}} \end{pmatrix}$$

$$r = \frac{M_{21}}{M_{11}} = \frac{\epsilon_2 k_{1z} - \epsilon_1 k_{2z}}{\epsilon_2 k_{1z} + \epsilon_1 k_{2z}}$$



$$E_x^{(1)}(z=0) = E_x^{(2)}(z=0) ,$$

$$B_y^{(1)}(z=0) - B_y^{(2)}(z=0) = \mu_0 \sigma_g E_x^{(1)}(z=0),$$

$$A_1 - B_1 = \frac{\epsilon_1 k_{2z}}{\epsilon_2 k_{1z}} (A_2 - B_2) ,$$

$$A_1 + B_1 = \frac{\sigma_g k_{2z}}{\omega \epsilon_0 \epsilon_2} (A_2 - B_2) + A_2 + B_2 .$$

The poles of r give the DR!!!

$$r = \frac{M_{21}}{M_{11}}$$

$$t = \frac{1}{M_{11}}$$

$$\epsilon_2 k_{1z} + \epsilon_1 k_{2z} = 0$$

$$\frac{k_2}{k_1} = -\frac{\epsilon_2}{\epsilon_1} \quad \text{SPP DR!}$$

$$r = \frac{1 - \frac{\epsilon_1 k_{2,z}}{\epsilon_2 k_{1,z}} + \frac{\sigma_g k_{2,z}}{\omega \epsilon_0 \epsilon_2}}{1 + \frac{\epsilon_1 k_{2,z}}{\epsilon_2 k_{1,z}} + \frac{\sigma_g k_{2,z}}{\omega \epsilon_0 \epsilon_2}}$$

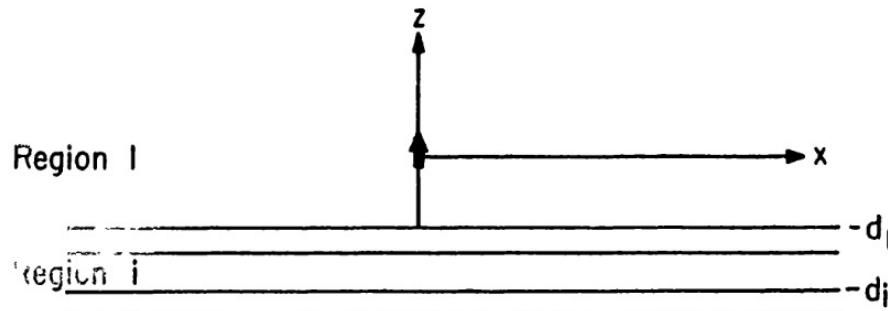
$$1 + \frac{\epsilon_1 k_{2,z}}{\epsilon_2 k_{1,z}} + \frac{\sigma_g k_{2,z}}{\omega \epsilon_0 \epsilon_2} = 0$$

$$k_{j,z} = i \sqrt{q^2 - \epsilon_j \omega^2 / c^2} \equiv i \kappa_j$$

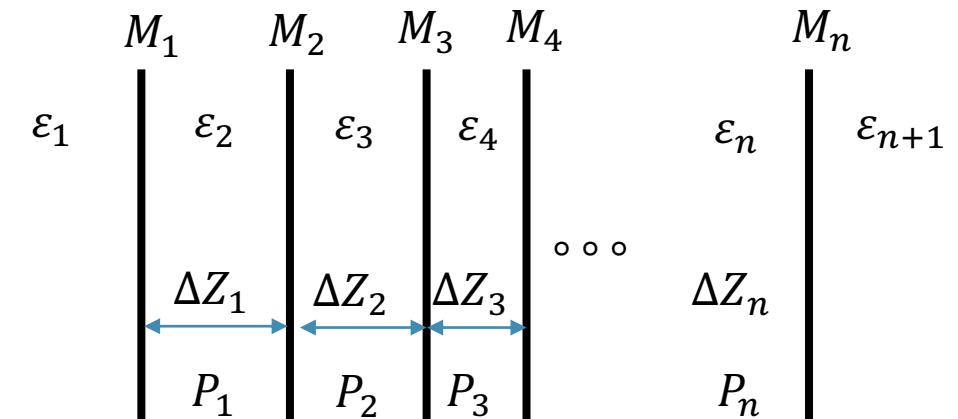
$$1 + \frac{\epsilon_1 \kappa_2}{\epsilon_2 \kappa_1} + \frac{i \sigma_g \kappa_2}{\omega \epsilon_0 \epsilon_2} = 0$$

$$\frac{\epsilon_1}{\kappa_1} + \frac{\epsilon_2}{\kappa_2} + \frac{i \sigma_g}{\omega \epsilon_0} = 0 \quad \text{GP DR!}$$

Polaritons, DR and the TMM



$$E_{1z} = \frac{-I\ell}{8\pi\omega\epsilon_1} \int_{-\infty}^{\infty} dk_\rho \frac{k_\rho^3}{k_{1z}} H_0^{(1)}(k_\rho\rho) \left[e^{ik_{1z}|z|} + R_{12}^{TM} e^{ik_{1z}z + 2ik_{1z}d_1} \right],$$



הקטבים של מקדם ההחזרה נתונים לנו
את יחס הדיספרסיה!

יחס הדיספרסיה נותן לנו את כל אופני
התנודה שנתמכים במערכת!

ה TMM נותן לנו את מקדם ההחזרה!

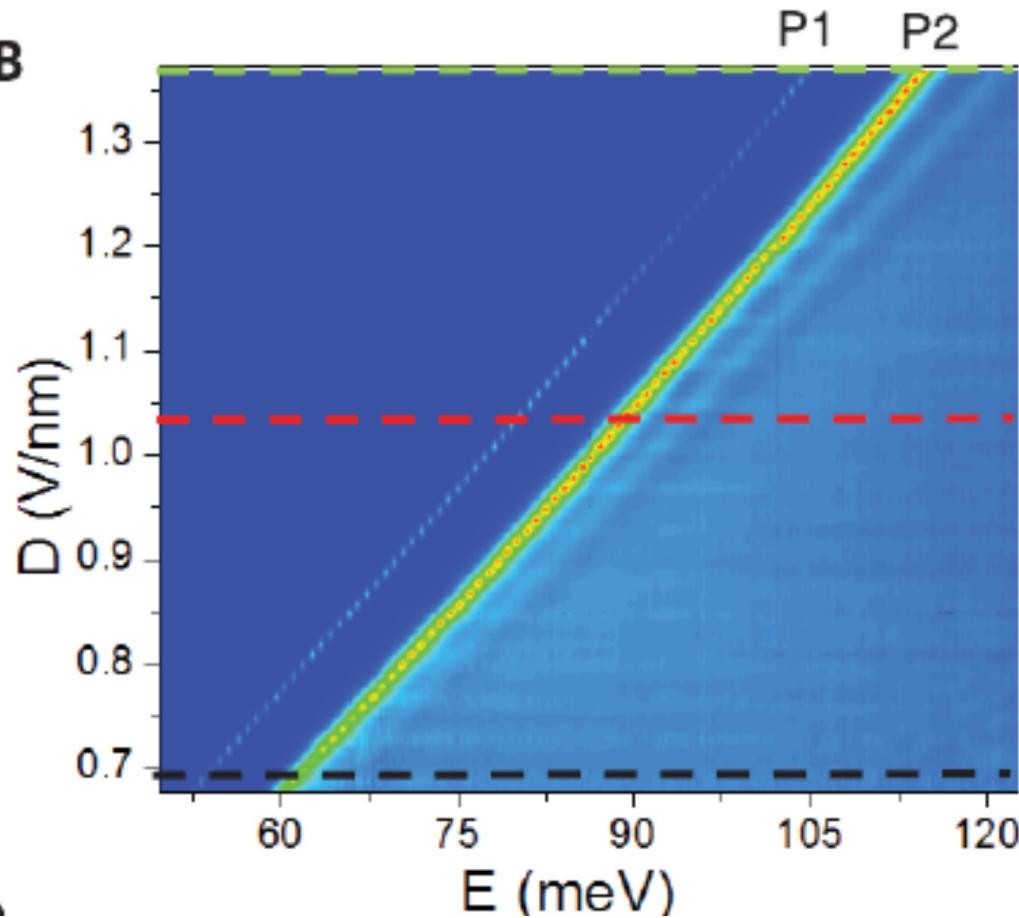
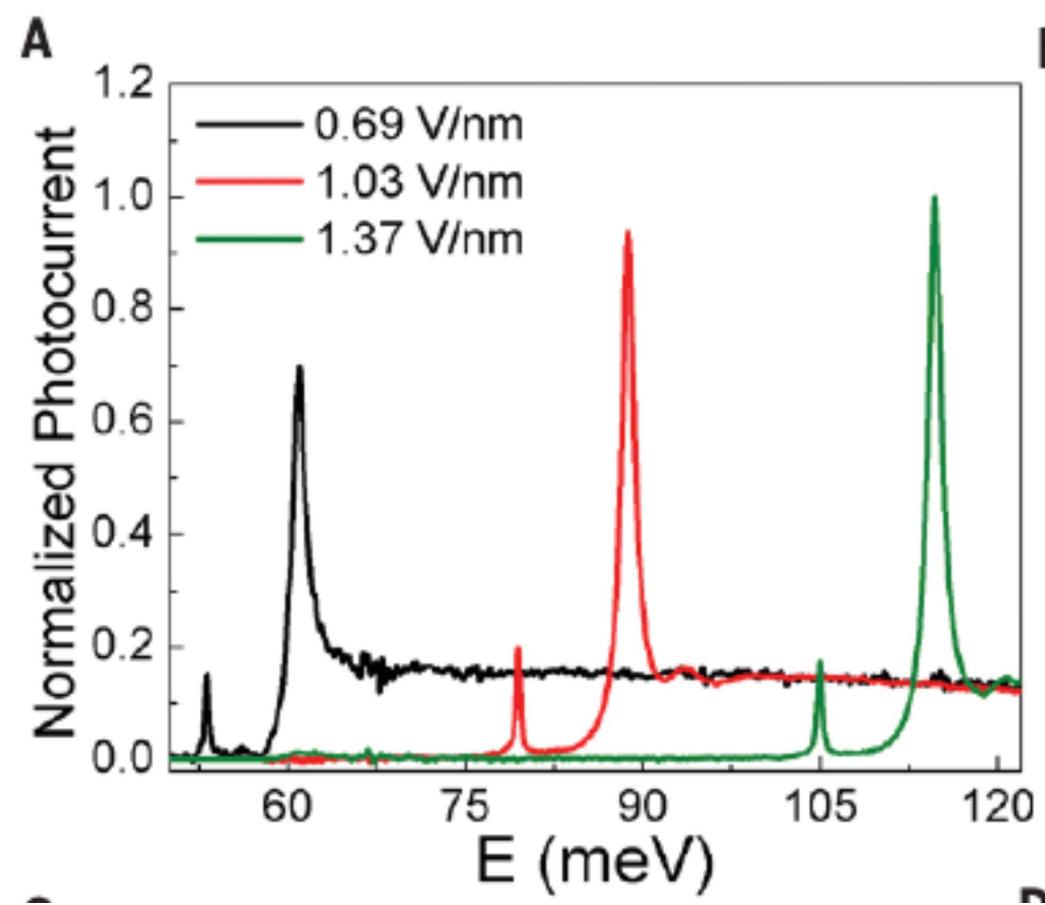
$$\begin{pmatrix} H_1^+ \\ H_1^- \end{pmatrix} = TM \begin{pmatrix} H_2^+ \\ H_2^- \end{pmatrix} \quad TM = M_1 P_1 M_2 P_2 \cdots M_{n+1}$$

$$r = \frac{M_{21}}{M_{11}}$$

The loss function $L_r(q, \omega)$ = $\text{Im } \{r\}$

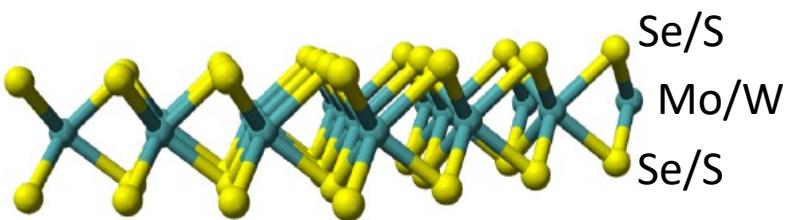
Needs to cover all the relevant
momentum/frequency space

Polaritons, DR and the TMM - examples

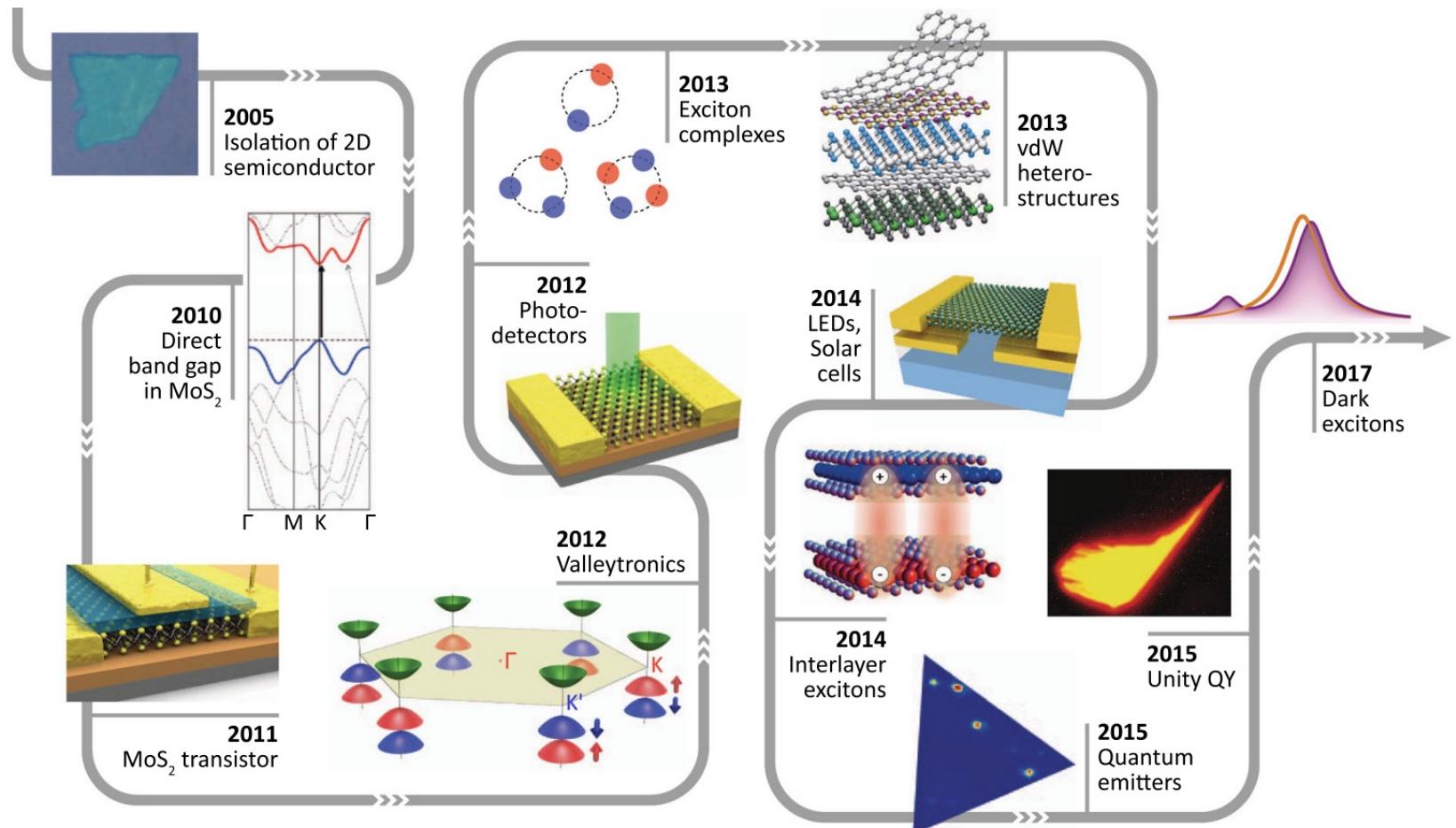


Transition-Metal-Dichalcogenides (TMDs)

Transition metal dichalcogenides



WS₂, WSe₂, MoS₂, MoSe₂



Transition-Metal-Dichalcogenides (TMDs)

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Emerging Photoluminescence in Monolayer MoS₂

Andrea Spaldiani^{†‡}, Liang Sun[†], Yuanbo Zhang[†], Tianshu Li[§], Jonghwan Kim[†], Chi-Yung Chim[†], Giulia Galli[§], and Feng Wang^{*†}

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Atomically Thin MoS₂: A New Direct-Gap Semiconductor

Kin Fai Mak, Changgu Lee, James Hone, Jie Shan, and Tony F. Heinz

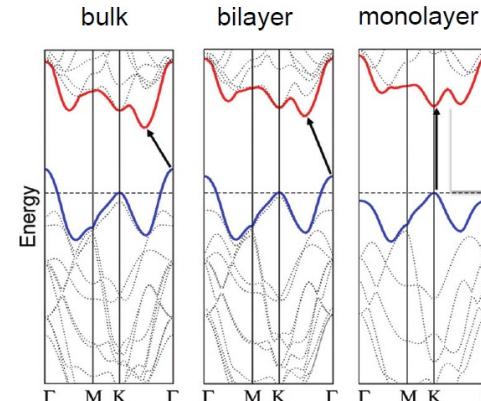
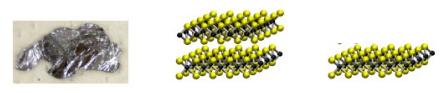
Phys. Rev. Lett. **105**, 136805 – Published 24 September 2010

Article References Citing Articles (9,593) Supplemental Material PDF HTML Export

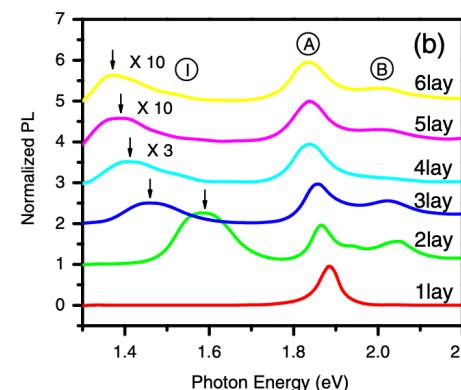
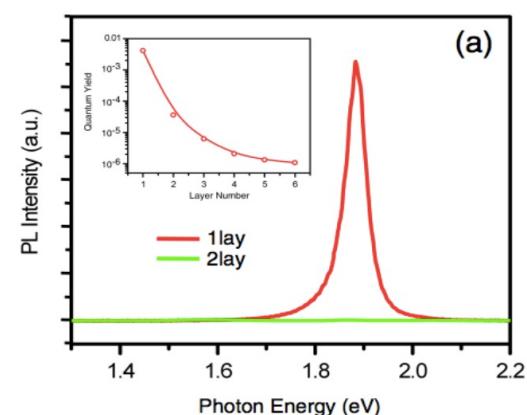


ABSTRACT

The electronic properties of ultrathin crystals of molybdenum disulfide consisting of $N = 1, 2, \dots, 6$ S-Mo-S monolayers have been investigated by optical spectroscopy. Through characterization by absorption, photoluminescence, and photoconductivity spectroscopy, we trace the effect of quantum confinement on the material's electronic structure. With decreasing thickness, the indirect band gap, which lies below the direct gap in the bulk material, shifts upwards in energy by more than 0.6 eV. This leads to a crossover to a direct-gap material in the limit of the single monolayer. Unlike the bulk material, the MoS₂ monolayer emits light strongly. The freestanding monolayer exhibits an increase in luminescence quantum efficiency by more than a factor of 10⁴ compared with the bulk material.

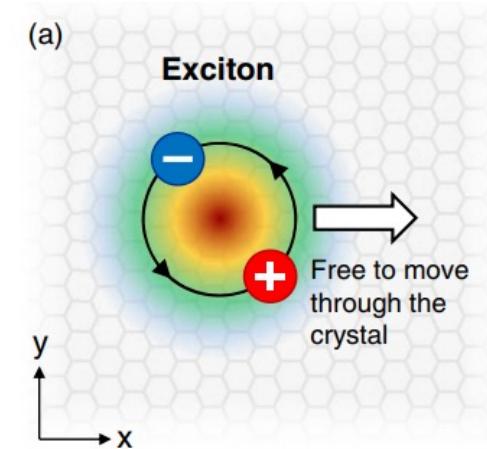
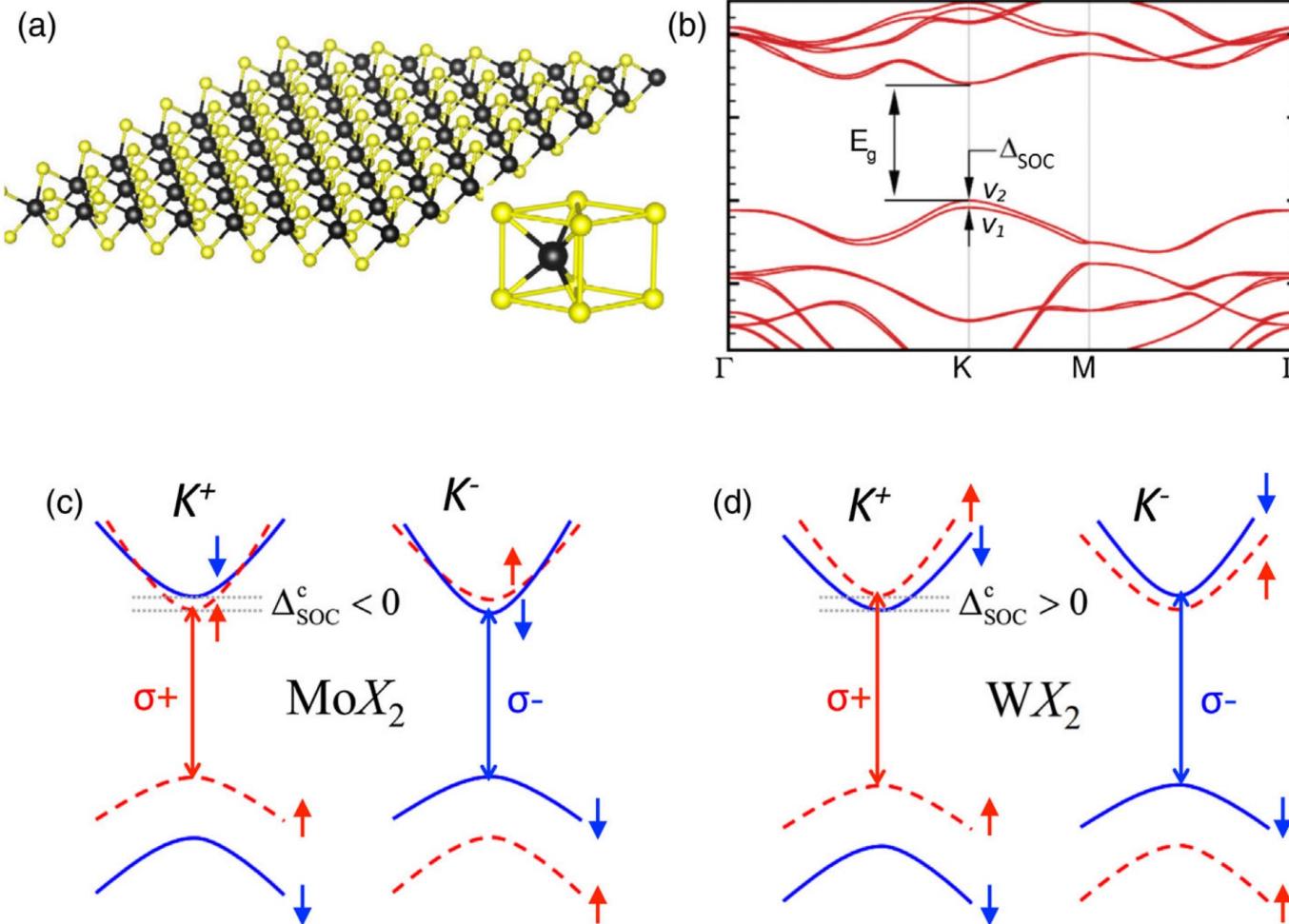


Spaldiani et al, *Nano Lett.* 10, 1271-1275(2010)

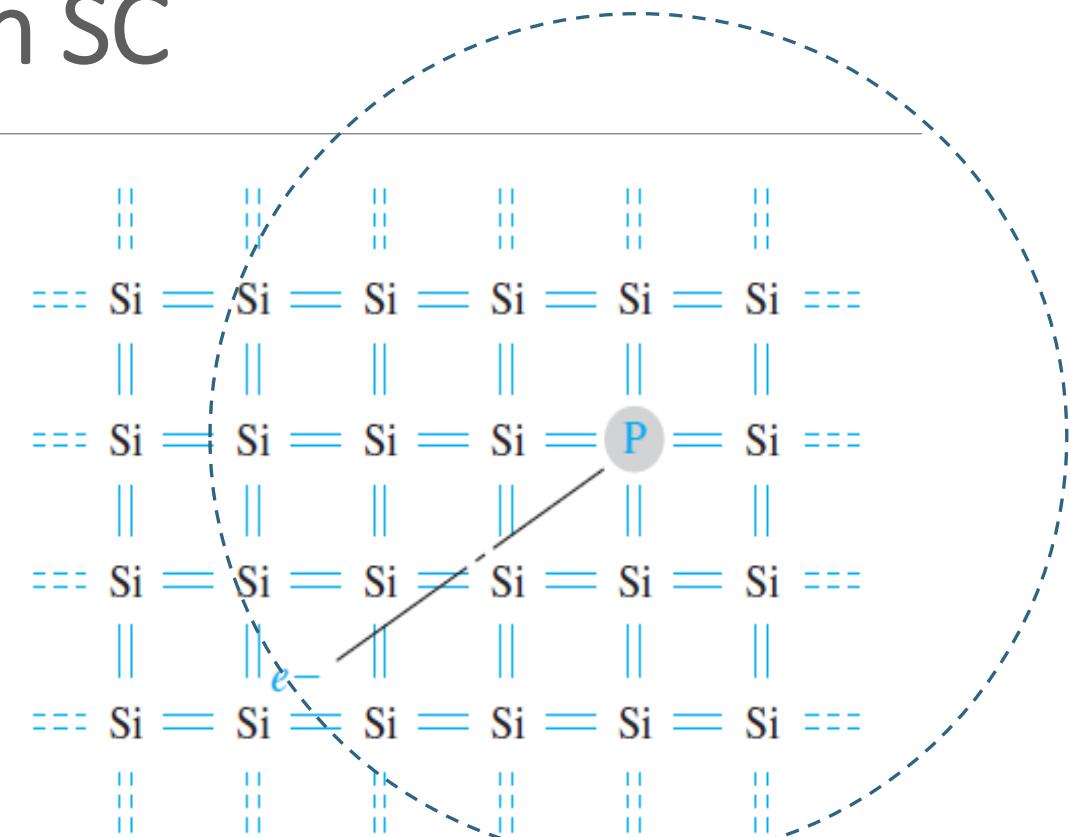
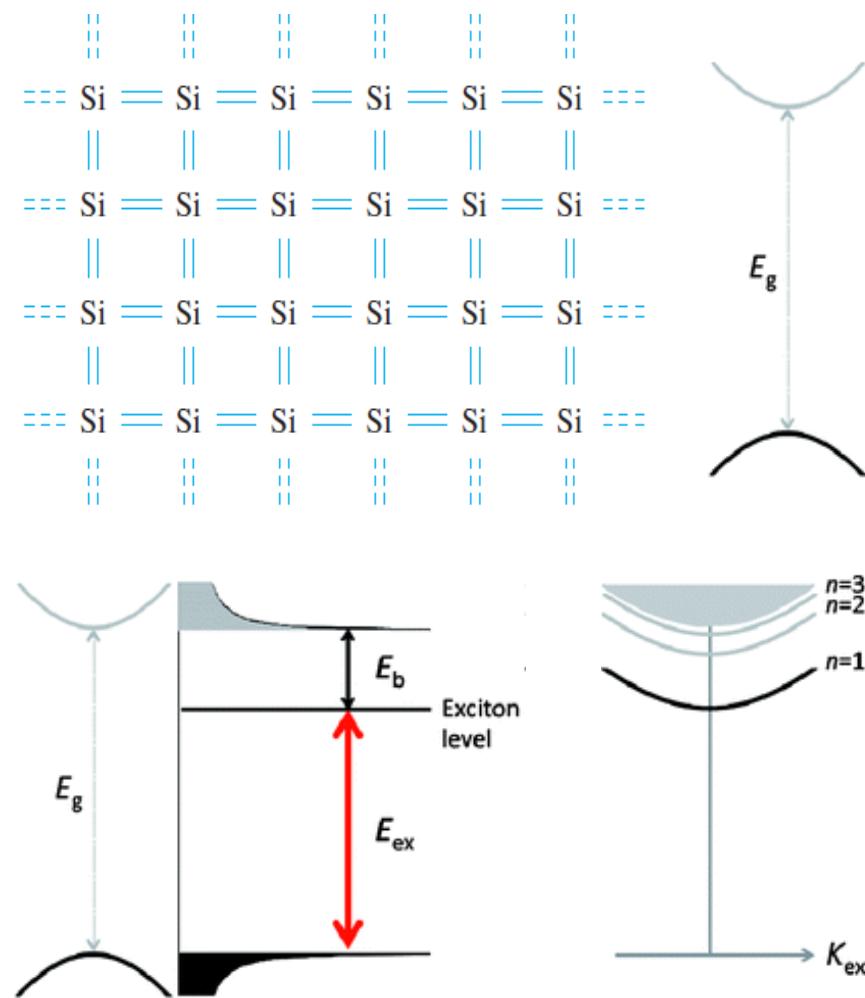


Mak et al, PRL 105, 136805 (2010)

Transition-Metal-Dichalcogenides (TMDs)

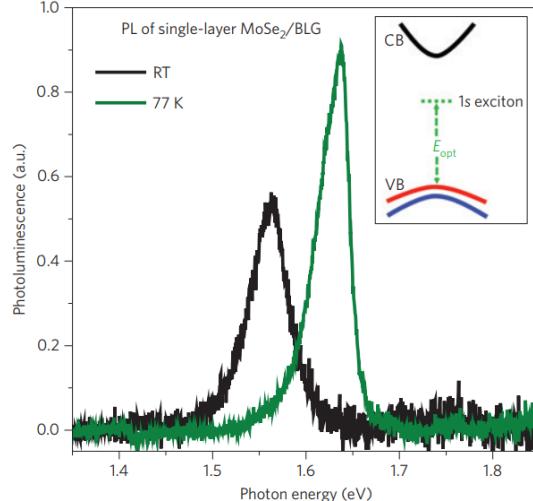


Excitons in SC

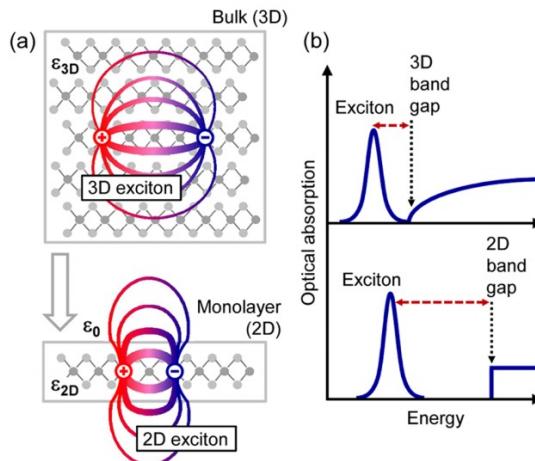


Excitons in monolayer TMDs

Ugeda et al, Nat. Mat. 13, 1091 (2014)

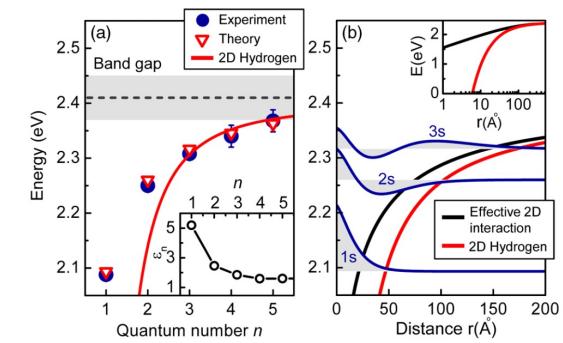
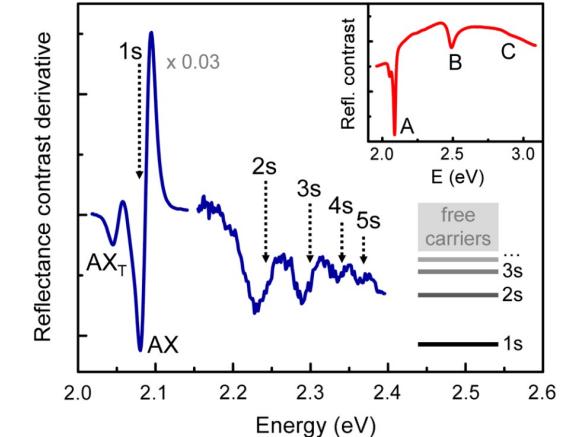


Chernikov et al, PRL 113, 076802 (2014)

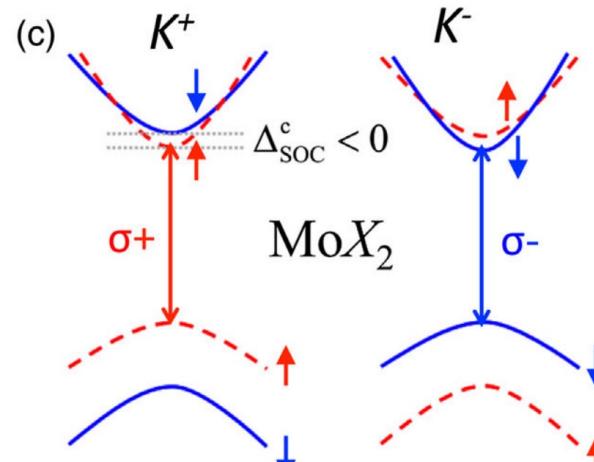


Material	Sample (temperature)	Experimental technique	Binding energy (eV)	Band gap (eV)	Reference
WSe ₂	Exf. on SiO ₂ /Si (RT)	Refl., 2P-PLE	0.37	2.02	He et al. (2014)
	CVD on HOPG (79 K)	STS, PL	0.5	2.2 ± 0.1	C. Zhang et al. (2015a)
	Exf. on SiO ₂ /Si (4 K)	PLE, 2P-PLE, SHG	0.6 ± 0.2	2.35 ± 0.2	Wang, Marie, Gerber et al. (2015)
	Exf. on SiO ₂ /Si (4–300 K)	Refl.	0.887	2.63	Hanbicki et al. (2015)
	CVD on HOPG (77 K)	STS, PL	≈0.4 ^a	2.08 ± 0.1	Chiou et al. (2015)
	Exf. on diamond (RT)	Mid-IR pump probe	0.245	1.9 ^b	Poellmann et al. (2015)
WS ₂	Exf. on SiO ₂ /Si (5 K)	Refl.	0.32 ± 0.04	2.41 ± 0.04	Chernikov et al. (2014)
	Exf. on fused silica (10 K)	2P-PLE	0.7	2.7	Ye et al. (2014)
	Exf. on SiO ₂ /Si (RT)	2P-PLE	0.71 ± 0.01	2.73	B. Zhu et al. (2014)
	Exf. on SiO ₂ /Si (4–300 K)	Refl.	0.929	3.01	Hanbicki et al. (2015)
	Exf. on fused silica (RT)	Refl., PLE	0.32 ± 0.05	2.33 ± 0.05	Hill et al. (2015)
	Exf. on fused silica (RT)	STS, Refl.	0.36 ± 0.06	2.38 ± 0.06	Rigosi et al. (2016)
MoSe ₂	CVD on SiO ₂ (4 K)	Magnetoreflection	0.26–0.48	2.31–2.53 ^b	Stier, McCreary et al. (2016)
	MBE on 2L graphene/SiC (5 K)	STS, PL	0.55	2.18	Ugeda et al. (2014)
MoS ₂	CVD on HOPG (77 K)	STS, PL	0.5	2.15 ± 0.06	C. Zhang et al. (2015a)
	Exf., suspended (77 K)	PC	0.2 (or 0.42)	2.15 ± 0.06	C. Zhang et al. (2014)
	Exf. on hBN/fused silica (RT)	PLE	≥ 0.57	2.5	Klots et al. (2014)
	CVD on HOPG (77 K)	STS, PL	0.44 ± 0.08 ^c	2.47 ± 0.08 ^c	Hill et al. (2015)
MoS ₂	Exf. on fused silica (RT)	STS, Refl.	0.31 ± 0.04	2.17 ± 0.1	Chiou et al. (2015)
	Exf. on fused silica (RT)	STS, Refl.	0.31 ± 0.04	2.17 ± 0.1	Rigosi et al. (2016)

**Direct bandgap + large binding energy =
Excitons dominate the optical response
of TMDS!!!**



Valley polarization



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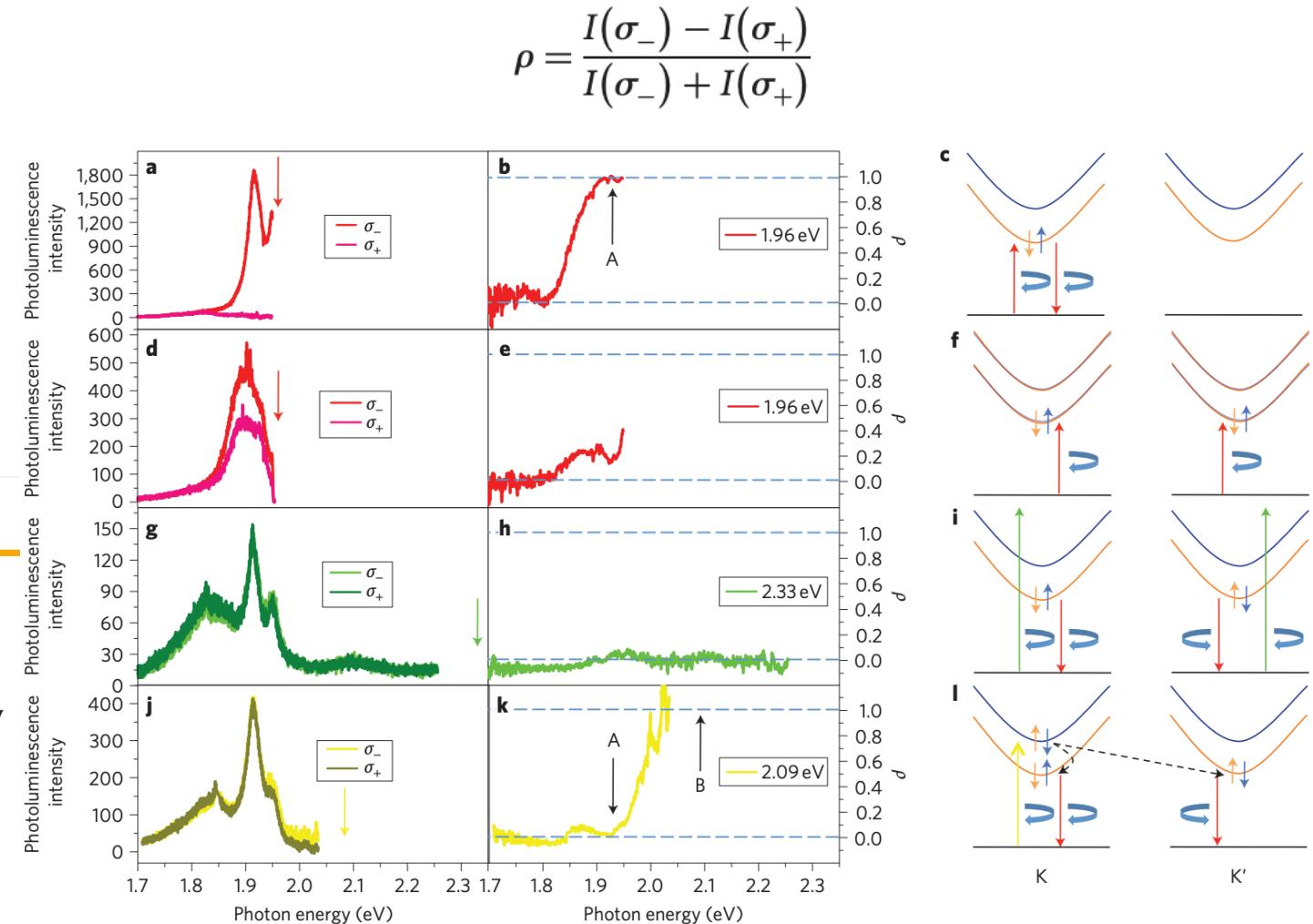
Published: 17 June 2012

Control of valley polarization in monolayer MoS₂ by optical helicity

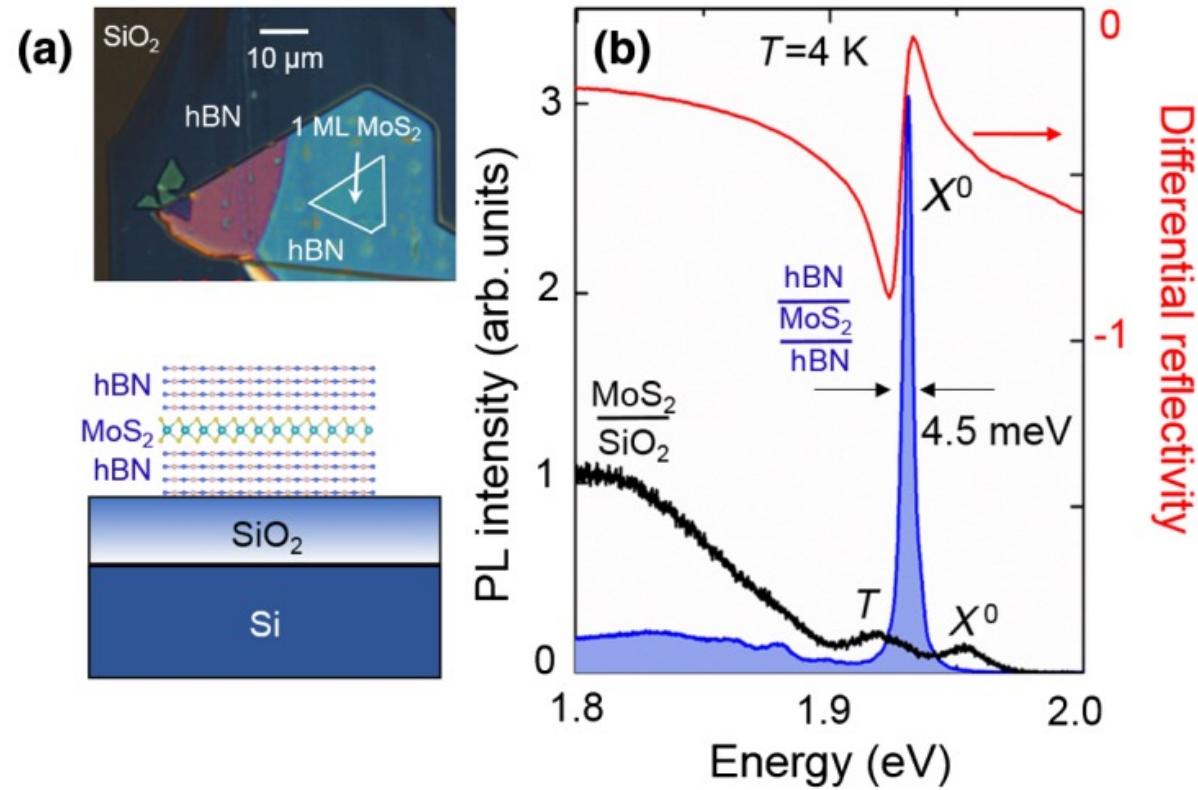
Kin Fai Mak, Keliang He, Jie Shan & Tony F. Heinz✉

Nature Nanotechnology 7, 494–498 (2012) | Cite this article

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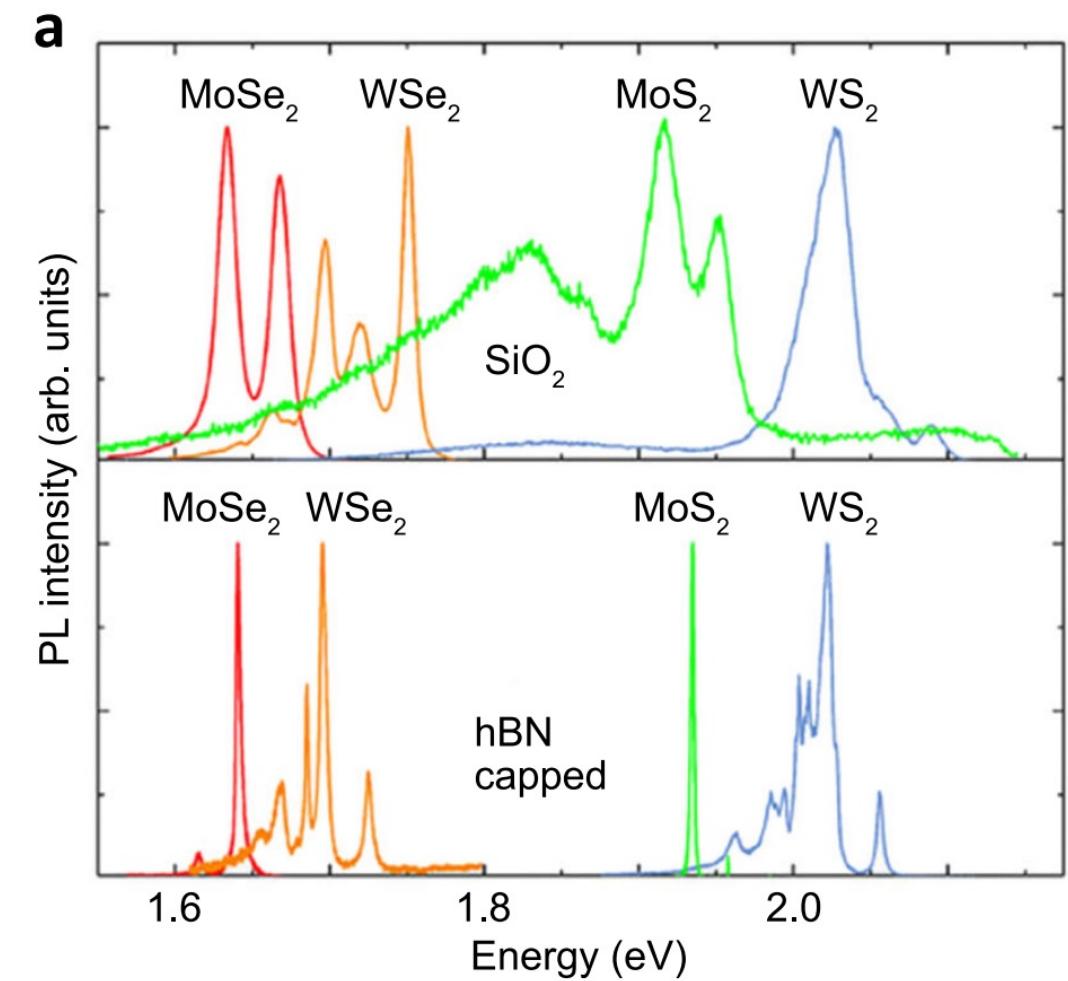


Excitons linewidth

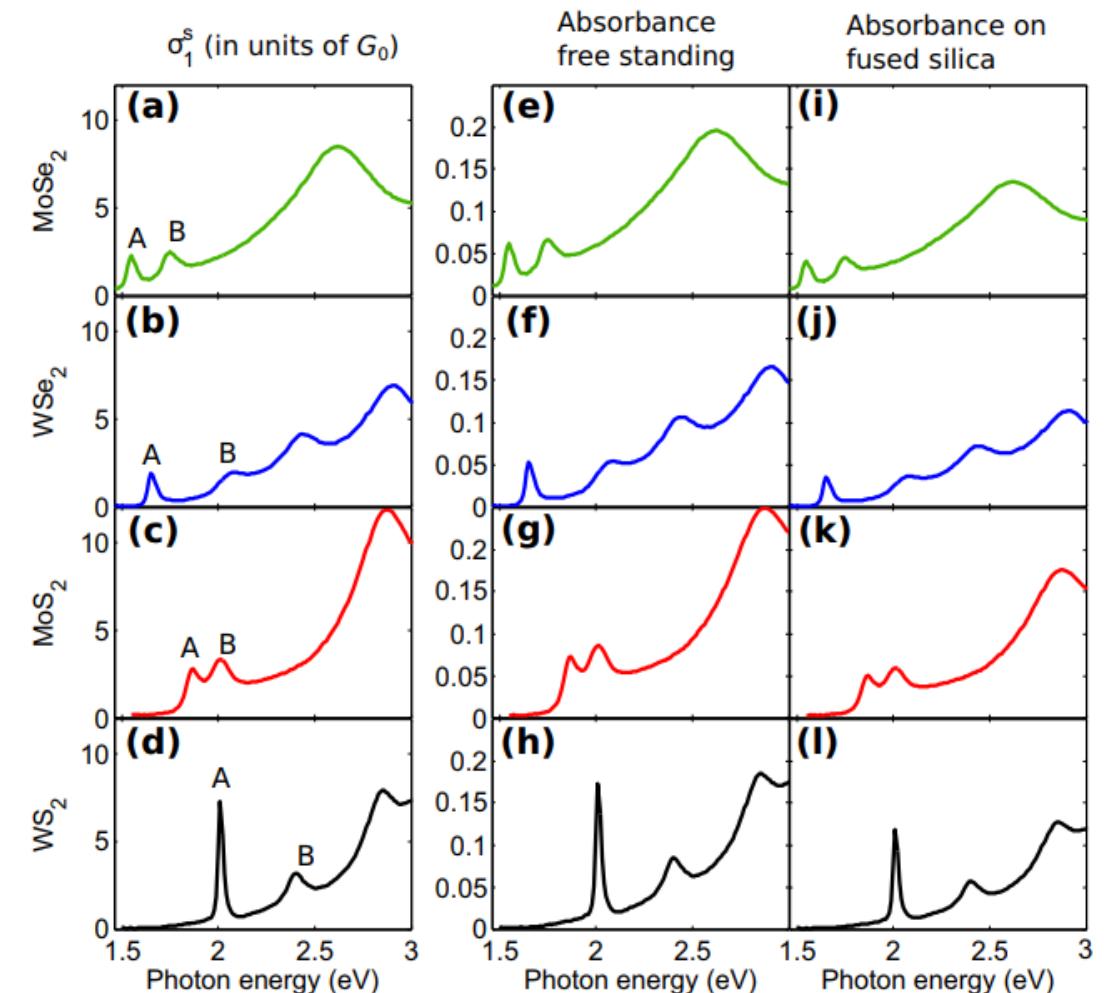
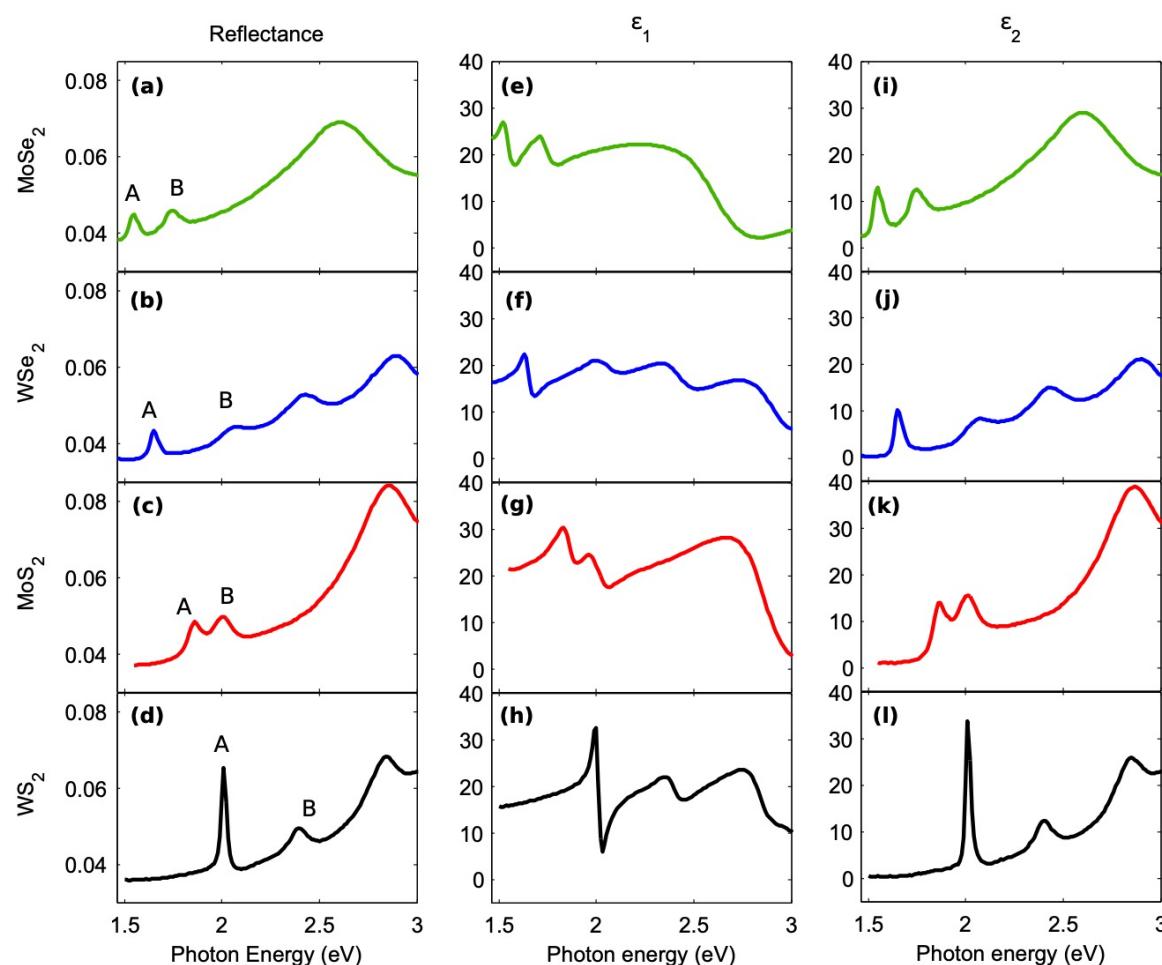


Cadiz et al, PRX 7, 021026 (2017)

Ajayi et al, 2D Mater. 4, 031011 (2017)



Optical properties



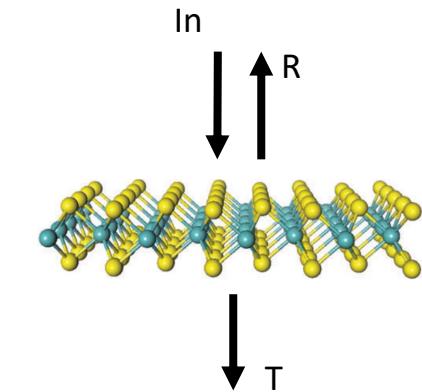
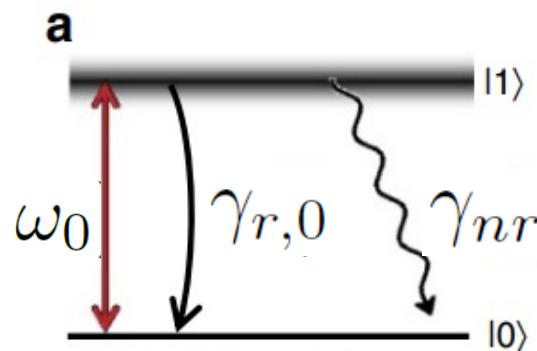
Monolayer TMD - Optical modeling

$$\tilde{\varepsilon}_r(\omega) = \tilde{\varepsilon}_r(\infty) + \omega_p^2 \sum_{m=1}^M \frac{f_m}{\omega_{0,m}^2 - \omega^2 - j\omega\Gamma_m}$$

$$\chi_{\text{in-plane}} = \chi_{bg} - \frac{c}{\omega_0 d_0} \frac{\gamma_{r,0}}{\omega - \omega_0 + i \frac{\gamma_{nr}}{2}} \quad \varepsilon = 1 + \chi$$

$$A(\omega) = \frac{2\gamma_{nr}\gamma_{r,0}}{4(\omega - \omega_0)^2 + (\gamma_{nr} + \gamma_{r,0})^2}$$

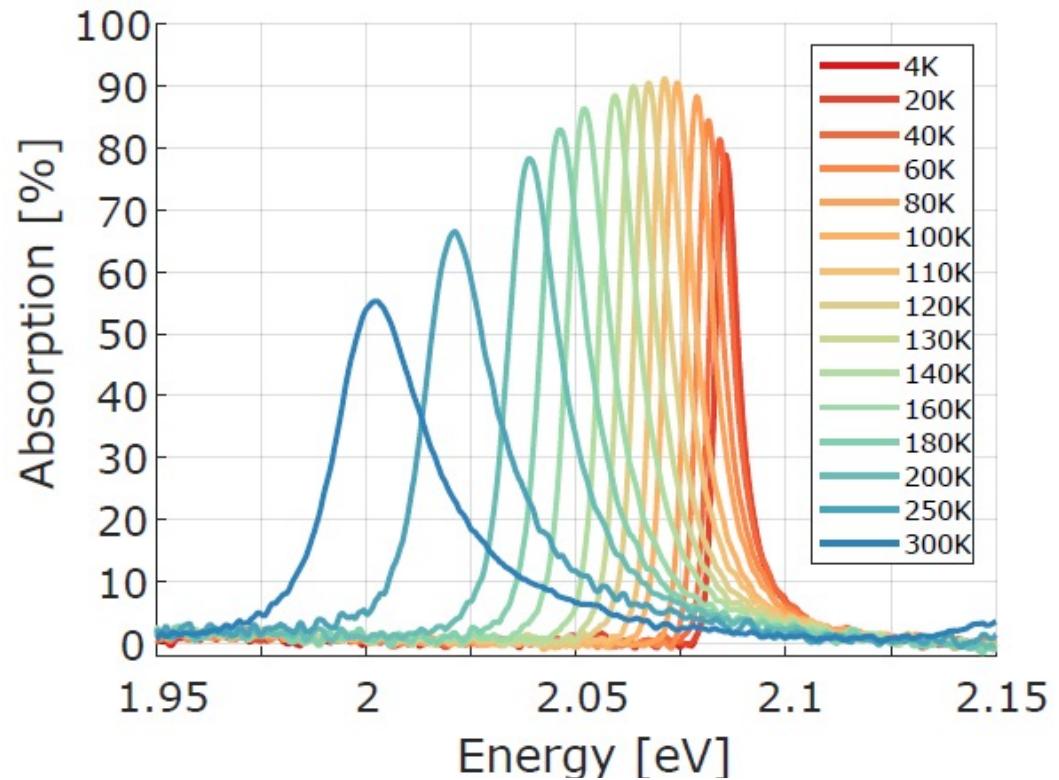
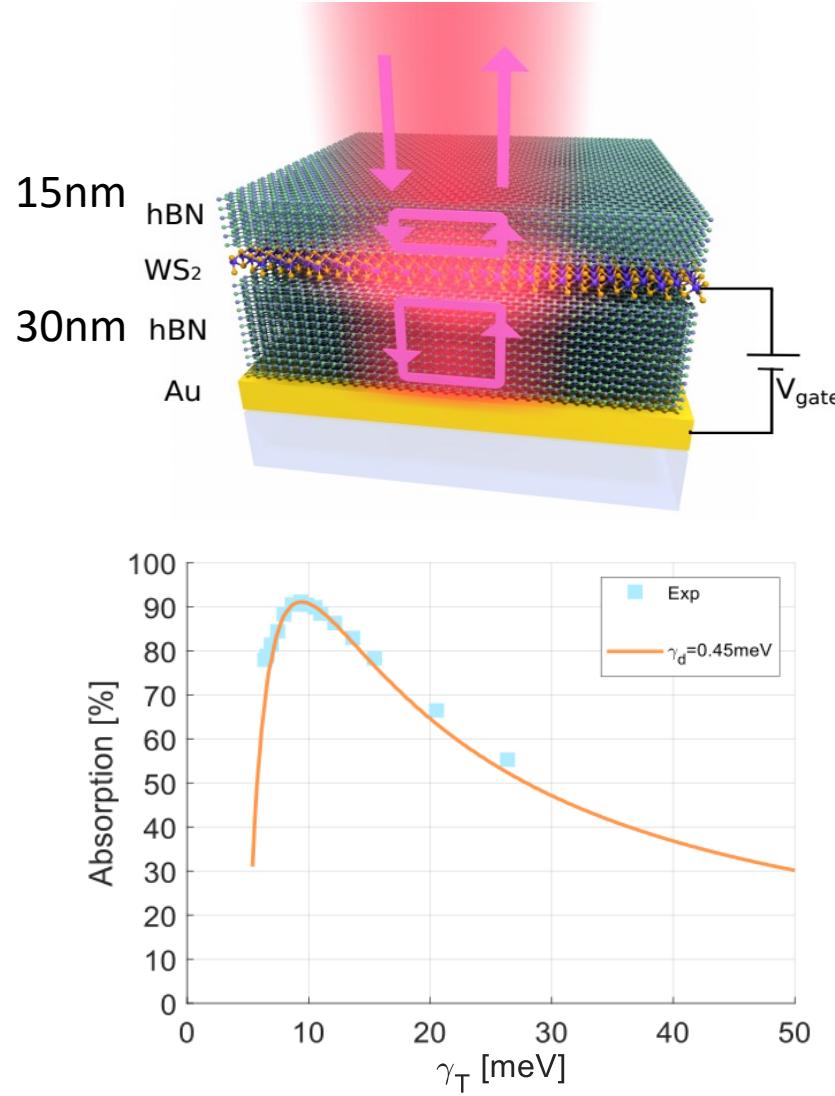
$\gamma_{r,0} \gg \gamma_{nr}$ $\gamma_{r,0} = \gamma_{nr}$ $\gamma_{r,0} \ll \gamma_{nr}$
 \downarrow \downarrow \downarrow
 $A(\omega) = 0$ A(ω) = 50% A(ω) = 0



$$R(\omega) = \frac{\gamma_{r,0}^2/4}{(\omega - \omega_0)^2 + (\gamma_{nr} + \gamma_{r,0})^2/4}$$

$\gamma_{r,0} \gg \gamma_{nr}$ \downarrow
 $R(\omega) = 1$
 $\gamma_{r,0} \ll \gamma_{nr}$ \downarrow
 $R(\omega) = 0$

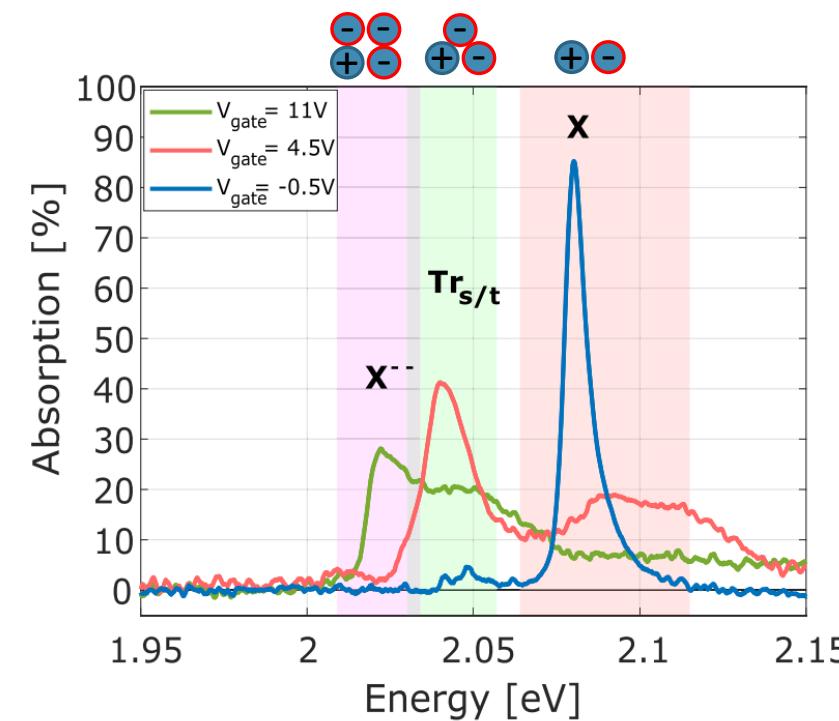
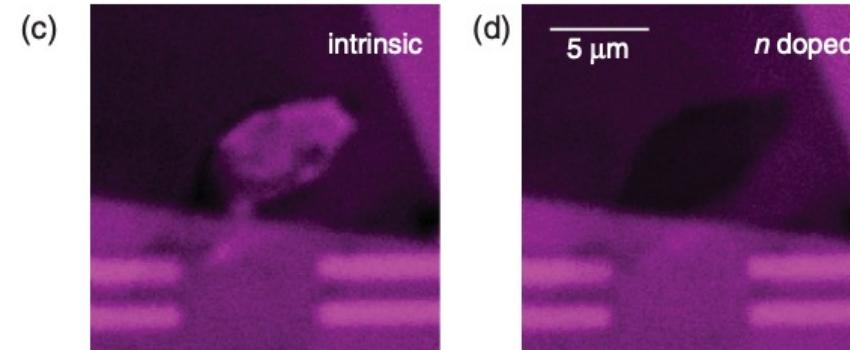
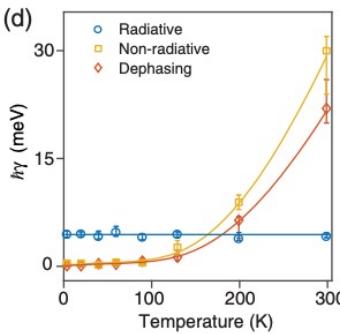
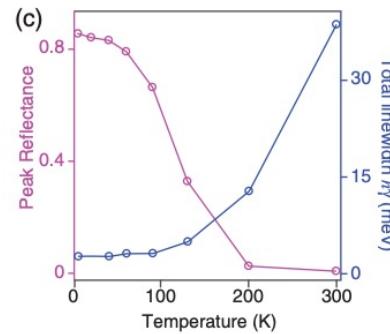
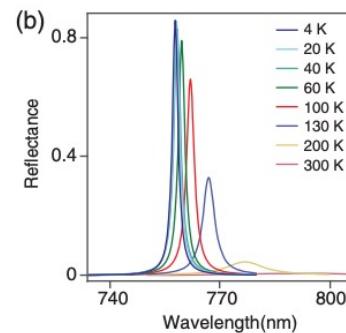
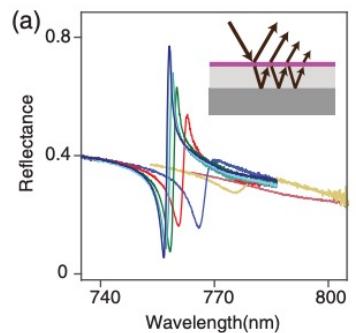
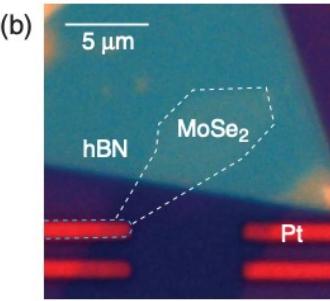
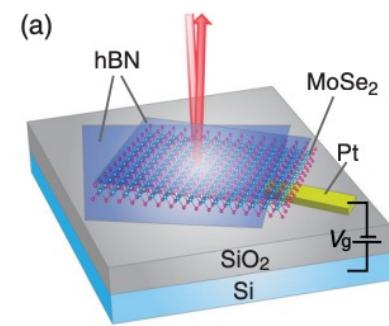
Controlling Optical properties of monolayer TMD



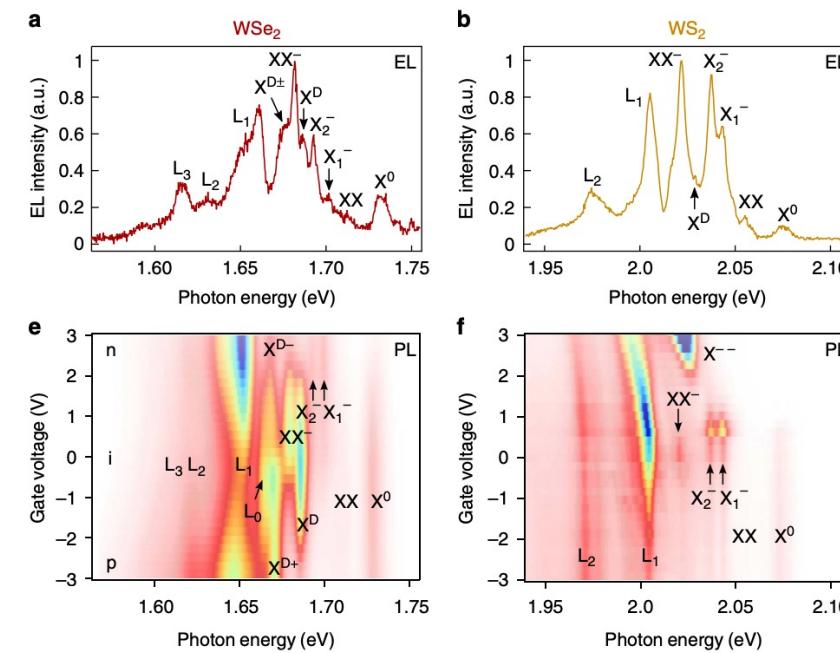
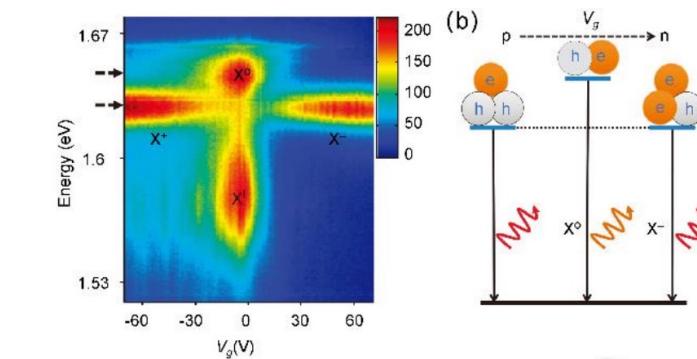
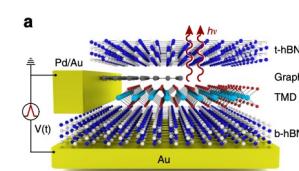
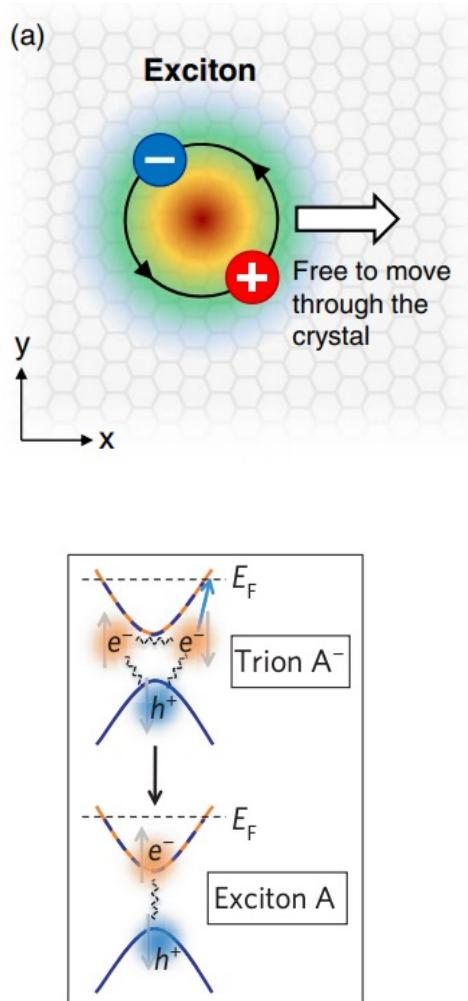
For TMM:

$$\chi_{\text{in-plane}} = \chi_{bg} - \frac{c}{\omega_0 d_0} \frac{\gamma_{r,0}}{\omega - \omega_0 + i(\frac{\gamma_{nr}}{2} + \gamma_d)}$$

Controlling Optical properties of monolayer TMD

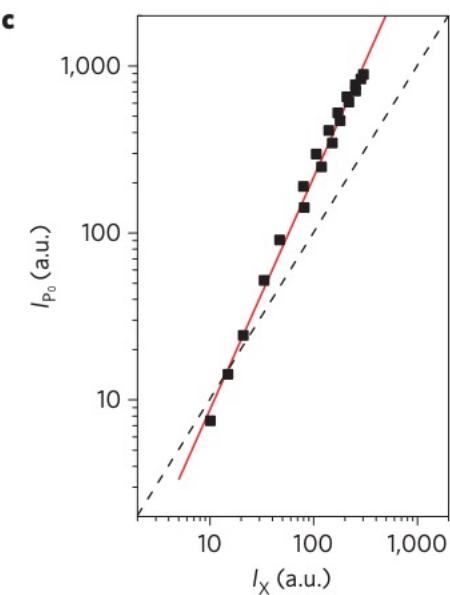
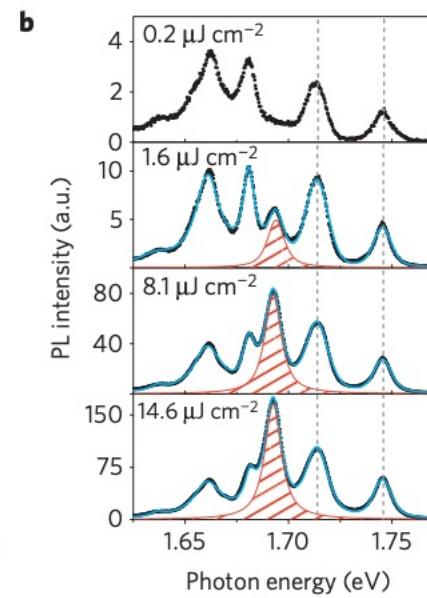
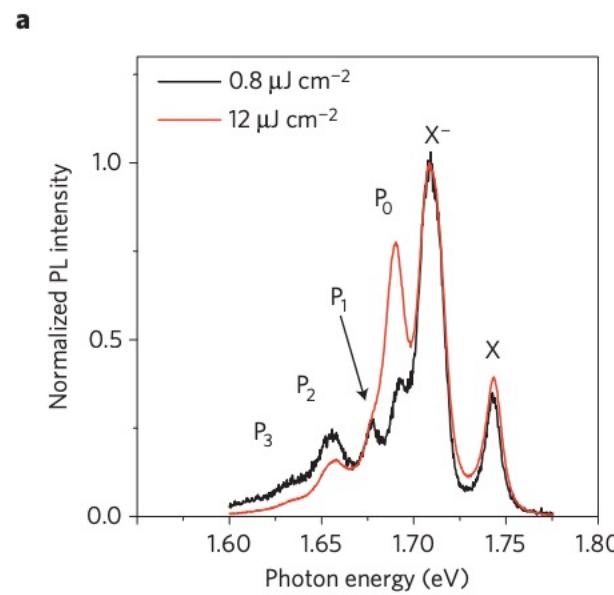
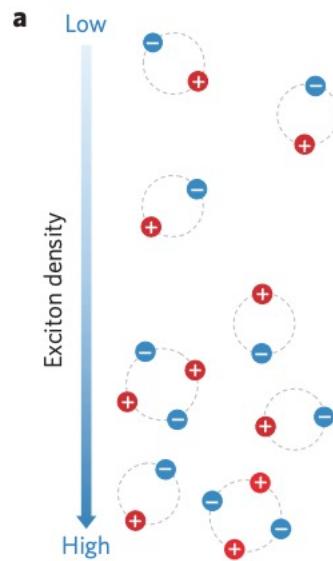


Exciton complexes



Exciton complexes

Biexcitons



$$I_{XX} \propto I_X^\alpha \text{ with } \alpha = 2$$